IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit:

Examiner:

2763

Not yet assigned

Attorney Docket No.: VLSI-3234 (PHA 780016)

Inventor(s):

Hubbard

Serial No.:

09/520,686

Filed:

Title:

3/7/00

WAFER TARGET DESIGN AND METHOD FOR DETERMINING CENTROID OF WAFF TARGET

The Commissioner of Patents and Trademarks Washington, D.C. 20231

Sir:

Information Disclosure Statement Submitted Pursuant to 37 C.F.R. 1.97(b)

The citations referenced herein, copies attached, may be material to the examination of the aboveidentified application and are, therefore, submitted in compliance with the duty of disclosure as defined in 37 C.F.R. 1.56. The Examiner is requested to make these citations of official record in the application.

This Information Disclosure Statement submitted in accordance with 37 C.F.R. 1.97(b) is not to be construed as a representation that a search has been made, that additional items material to the examination of this application do not exist, or that any one or more of these citations constitute prior art under 35 U.S.C. 102.

The Examiner's attention is respectfully directed to the following U.S. Patents:

Pat. No.	Pat. Title	Grant Date
4,253,112	PROCESS FOR AUTOMATIC ALIGNMENT OF TWO OBJECTS TO BE ADJUSTED WITH RESPECT TO ONE ANOTHER	2/24/81
5,760,484	ALIGNMENT MARK PATTERN FOR SEMICONDUCTOR PROCESS	6/2/98
4,880,309	DARK FIELD TARGET DESIGN SYSTEM FOR ALIGNMENT OF SEMICONDUCTOR WAFERS	TC 2800 N
	Other Documents	EIVI 17 2 MAIL
PATENT ABSTRA 013306 A (Fujitsu	ACTS OF JAPAN, vol. 017, no. 272 (E-1371), 26 May 1993 (1993-05) Ltd), 22 January 1993 (1993-01-22) abstract; figures	5-26) - EJP 05

Please direct all correspondence concerning the above-identified application to the following address:

WAGNER, MURABITO & HAO LLP Two North Market Street, Third Floor San Jose, California 95113

(408) 938-9060

Respectfully submitted,

Date:_	10/4	-1/01
		,

John P. Wagner, Jr. Reg. No. 35,398

1

Technology Center 2100 Attorney Docket No.: VLSI-3234 (PHA 780016)

Not yet assigned

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2763

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Title:

WAFER TARGET DESIGN METHOD FOR DETERMINING CENTROID OF WAFER

Examiner:

Group Art Unit:

TARGET

Form 1449

U.S. Patent Documents

Examiner		·				Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
	Α	4,253,112	2/24/81	Doemens	358	101	5/21/79
	В	5,760,484	6/2/98	Lee et al.	257	797	2/11/97
	С	4,880,309	11/14/89	Wanta	356	401	4/14/87
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Foreign Patent or Published Foreign Patent Application

Examiner		Document	Publication	Country or		Sub-	Tran	slation
Initial	No.	No.	Date	Patent Office	Class	class	Yes	No
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Other Documents

Examiner		
Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	S	PATENT ABSTRACTS OF JAPAN, vol. 017, no. 272 (E-1371), 26 May 1993 (1993-05-26) -& JP 05 013306 A (Fujitsu Ltd), 22 January 1993 (1993-01-22) abstract; figures
	T	
Examiner		Date Considered

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered.

Include copy of this form with next communication to applicant.

Docket No.: VLSI-3234 (PHA 780016)

Not yet assigned

Information Disclosure Stat m nt Transmittal

Thereby certify that this transmittal of the below described document is being deposited with the United States Postal Service in an envelope bearing First Class Postage and addressed to the Commissioner of Patents and Trademarks, Washington, D.C., 20231, on the below date of deposit.

Date of Deposit:

Name of Person Making the Deposit:

IN THE UNITED JENT AND TRADEMARK OFFICE

0 9 2001

Inventor(s):

Hubbard

Serial No.:

09/520,686

Filed:

Title:

3/7/00

ECEIVEL 1001 Center 2' WAFER TARGET DESIGN AND METHOD FOR DETERMINING CENTROID OF WAFER

Group Art Unit:

Examiner:

2763

TARGET

The Commissioner of Patents and Trademarks

Washington, D.C. 20231

Sir:

Information Disclosure Statement Transmittal

Transmitted herewith is the following: Formal drawings, totaling Informal drawings, totaling sheets. x Certification for PTO Consideration x Information Disclosure statement (1 sheets) Information Disclosure statement and late filing fee Form 1449 Petition for Extension of Time Other:

F e Calculation (for other than a small entity)		شمین		
Fee Items	Fee Rate	Total		
Petition for Extension of Time (fee calculated elsewhere	\$.00	0.00		
Information Disclosure Statement, late filing	\$240.00	0.00		
Other:				
T tal Fees				

PAYMENT OF FEES

- 1. The full fee due in connection with this communication is provided as follows:
- [] The Commissioner is hereby authorized to charge any additional fees associated with this communication or credit any overpayment to Deposit Account No.: 23-0085. A duplicate copy of this authorization is enclosed.
- [] A check in the amount of \$
- [X] Charge any fees required or credit any overpayments associated with this filing to Deposit Account No.: 23-0085.

Please direct all correspondence concerning the above-identified application to the following address:

WAGNER, MURABITO & HAO LLP

Two North Market Street, Third Floor San Jose, California 95113 (408) 938-9060

Respectfully submitted,

Date:	10/4/01	By:
		John P. Wagner, Jr.
		Reg. No. 35,398

OCT 1 2 2001
Technology Center 2100

Docket No.: VLSI-3234 (PHA 780016)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Thereby certify that this transmittal of the below described document is being deposited with the United States Postal Service in an envelope bearing First Class Postage and addressed to the Assistant Commissioner for Patents, Washington, D.C., 20231, on the below date of deposit. Name of Person Signature of the Person Making the Deposit: 10/4/01 Karen Yarr Deposit: Making the Deposit: Inventor(s): Hubbard Serial No.: 09/520,686 Group Art Unit: 2763 Filed: Examiner: 3/7/00 Not yet assigned WAFER TARGET DESIGN Title: THOD FOR DETERMINING CENTROID OF WAFER TARGET The Assistant Commissioner for Patents Washington, D.C. 20231 Sir: Certification for PTO Consideration of an Information Disclosure Statement (Under 37 CFR §1.97) Consideration of the enclosed Information Disclosure Statement is requested. This certification is being made for this information disclosure statement 2. I hereby certify that: X Each item of information contained in the information disclosure more than three months prior to the filing of the statement. No item of information contained in the information disclosure statement was cited in a communication from a foreign patent office in a counterpart application, or, to the knowledge of the person signing certification after making reasonable inquiry, was known to any individual designated in §1.56(c) more than three months prior to the filing of the statement. 3. The person making this certification is [x] a person who is substantively involved in the preparation or prosecution of the application, and who is associated with the inventor, with the assignee, or with anyone to whom there is an obligation to assign the application (37 C.F.R. 1.56 (c)) and who signs below. [] the inventor(s) who signs below [] the practitioner who signs below on the basis of the information: [] supplied by the inventors [] supplied by an individual designated in § 1.56(c) [] in the practitioners file

Please direct all correspondence concerning the above-identified application to the following address:

WAGNER, MURABITO & HAO LLP

Two North Market Street, Third Floor San Jose, California 95113 (408) 938-9060

Respectfully submitted,

Date: 10 401

By: / John P. Wagner, Jr. Reg. No. 35,398

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Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub- class	Filing Date
IIIIIIai		4,253,112	2/24/81	Doemens	358	101	5/21/79
	I A B	5,760,484	6/2/98	Lee et al.	257	797	2/11/97
	C	4,880,309	11/14/89	Wanta	356	401	4/14/87
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Foreign Patent or Published Foreign Patent Application

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Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	class	Yes	
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Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	S	PATENT ABSTRACTS OF JAPAN, vol. 017, no. 272 (E-1371), 26 May 1993 (1993-05-26) -& JP 05 013306 A (Fujitsu Ltd), 22 January 1993 (1993-01-22) abstract; figures
	T	
Examiner	-	Date Considered

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